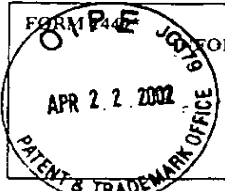


Date Mailed: April 22, 2002

Sheet 1 of 1

	INFORMATION DISCLOSURE STATEMENT		Docket Number: 40222.0003USC1	Application Number: 10/023,365
	IN AN APPLICATION		Applicant: Teruo Umemoto	
	(Use several sheets if necessary)		Filing Date: December 14, 2001	Group Art Unit: 1741 <b>753</b>

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
<i>JS</i>	5,902,907	05/11/99	Takahashi et al.	568	321	
<i>JS</i>	5,942,641	08/24/99	Tanaka et al.	560	139	
			/			
FOREIGN PATENT DOCUMENTS						
	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
						YES NO
<i>JS</i>	SHO 61-271323	12/01/86	Japan			X
			/			
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)						
<i>JS</i>	1999 *	<i>A Precursor Route to 2,7-Poly (9-fluorenone), Macromolecules 32, 4519-4524, Uckert et al.</i>				
<i> </i>	March 1985	<i>The Electrochemical Oxidation and Polymerization of Polycyclic Hydrocarbons, Electrochemical Science and Technology, 631-634, Waltman et al.</i>				
<i> </i>	September 23, 1985	<i>The Polyfluorenes: A Family of Versatile Electroactive Polymers; Electropolymerization of Fluorenes; New Journal of Chemistry, Vol. 10, Rault-Berthelot et al.</i>				
<i> </i>	2000 *	<i>2,7-Poly (9-fluorenone); A Trap-Free Electron-Injection Material with a High Charge Carrier Mobility for Use in Light-Emitting Diodes, Advances Materials, 2000, 12, No. 12, Uckert et al.</i>				
<i> </i>	May 1986	<i>Redox Polymer Films From Cathodic Coupling of 4,4'-Dibromobenzophenone and 2,7-Dibromofluorenone, J. Electroanal. Chem, 215 (1986) 377-383, Zecchin et al.</i>				
<i> </i>	September 20, 1984	<i>Anodic and Cathodic Deposition of Electroactive Polyfluorene Films J. Electroanal. Chem.. 186 (1985) 191-199, Schiavon et al.</i>				

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EXAMINER <i>Eone Wong</i>	DATE CONSIDERED <i>11/14/03</i>
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.	